

Titel:

Electron Beam Lithography Systems from Vistec - An Innovative, Flexible and Productive Patterning Solution

Company profile:

Vistec Electron Beam GmbH provides leading technology solutions for advanced electron-beam lithography. Based on the Variable Shaped Beam (VSB) principle, the electron-beam lithography systems are mainly utilized for semiconductor applications, as silicon and compound semiconductor direct write, mask making as well as integrated optics and several new emerging markets and advanced research. The company is located in Jena, Germany and maintains service & support centers in Europe, Taiwan & in the US.